Technology	TP
Platform Type	300MM VANTAGE 3.X
Application	DENSIFICATION / REFLOW
Wafer Size	300MM (12 INCH)
Wafer Shape	SNNF
Position A	(V352) RadOx2
Position B	(V352) RadOx2
Chamber A Process	TOXIC RP
Chamber B Process	TOXIC RP
WIP Delivery Type	OHT WIP DELIVERY
Wafer Pass Thru and Storage	DUAL 2 SLOT ACTIVE COOLDOWN STATION
Remote Control System Capable	NO
Docked E99 Reading Capability	YES
Loadport Types	SELOP 7
Load Port Operator Interface	STANDARD 8 LIGHT
Configurable Colored Lights	YES
Ionizing Systems	NONE
Air Intake Systems	TOP INTAKE
E84 Carrier Handoff	UPPER E84 INTERFACE ENABLED OHT
E84 PIO Sensors and Cables	UPPER E84 SENSORS AND CABLES
E99 Carrier ID	TIRIS WITH RF
Carrier ID Host Cntrl Intrfc	NO
Operator Access Switch	YES
LIGHT TOWERS	4 COLOR CONFIGURABLE LIGHT TOWER
Interface A Option	YES
eDiagnostic Ready	YES
eDiagnostics	NONE
FI Hot Blade - U BLADE	NONE
FI MEE BLADE	NONE
Out The Back Connection Type	RP
Out The Back Connection NH3	NO
Out The Back Connection H2	YES
Chamber Water Cooling Kits	TWO CHAMBER
RP Integration Hardware	CHAMBER A and B
Rear Light Tower	Standard RAGB
System Software	CGA
Vantage Skins	TWO CHAMBER TOXIC
LL/Transfer Pump	iPUP
Monitor 1	17 IN FLAT PANEL WITH KEYBOARD ON STAND
Monitor 2	REMOTE 17 IN FLAT PANEL ON STAND
Monitor 1 Cables	25FT WITH 16 FEET EFFECTIVE
Monitor 2 Cables	25FT WITH 16 FEET EFFECTIVE
Heat Exchanger Type	NONE
Heat Exchanger Quantity	ZERO
RTP Abatement Unit	NONE

SEMI F47	YES
System Labels	ENGLISH ONLY
Semi S2 compliance	YES
RTP Chamber Type	RADIANCE RADOX 2 300MM
Technology Option	OPEN LOOP TUNER
MFC Type	STEC
Core Anneal and RTO	YES
Ammonia Anneal	NONE
BPSG Anneal	NOT APPLICABLE
Rotation Type	WRLD TOXIC
Low Flow O2	5 SLM
High Flow O2	50 SLM
Oxygen Analyzer	YES
H2	HIGH FLOW LOW FLOW AND SIDE INJECT
Process N2 for Flammable MNFLD	NO
Gas Pallet Type	TOXIC RP COMMON GAS PALLET
MWBC Improvement Kit	Reflector plate with quartz cover to extend MWBC
Chamber Integration Lines	RadOx 2
RP Pump cable	81 Feet
Base Ring	Radox2 base ring
Line 1	N2 (N/O), 50 SLM
Line 2	O2, 50 SLM
Line 3	O2, 5 SLM
Line 4	-
Line 5	-
Line 6	H2, 15 SLM - Side Inject High Flow
Line 7	H2, 22 SLM - High Flow
Line 8	H2, 2 SLM - Low Flow
Line 9	-
Line 10	N2 (P/P), 30 SLM Restrictor
Line 11	He, 30 SLM
Line 12	N2 (BP), 50 SLM
Line 13	N2 (Maglev), 100 SLM
RTP Chamber Type	RADIANCE RADOX 2 300MM
Technology Option	OPEN LOOP TUNER
MFC Type	STEC
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BPSG Anneal	NOT APPLICABLE
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